To: Commissioner of Patents and Trademarks Washington, D.C. 20231

Fr: George O. Saile

Reg. No. 19,572

28 Davis Avenue

Poughkeepsie, N.Y. 12603

Subject:

**Divisional Patent Application** of

Serial No.: 10/227,697 8/26/02

WENHE LIN, MEI SHENG ZHOU, KIN LEONG PEY,

SIMON CHOOI

METHODS TO FORM DUAL METAL GATES BY

INCORPORATING METALS AND THEIR CONDUCTIVE

**OXIDES** 

## PRELIMINARY AMENDMENT

Dear Sir:

This is a preliminary amendment for the above referenced Divisional Patent

Application. Please amend the above identified application for patent as follows:

## **CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents and Trademarks, Washington, D.C. 20231, on December 16, 2003.

Stephen B. Ackerman, Reg. No. 37,761

Signature/Date